

Photoresist and Photoresist Ancillaries 2017 Global Market Expected to Grow at CAGR 5.98 % and Forecast to 2021

WiseGuyReports.com adds "Global Photoresist and Photoresist Ancillaries Market 2017-2021 " reports to its Database.



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[Photoresist and Photoresist Ancillaries SWOT Analysis And Forecast 2022](#)

About Photoresist and Photoresist Ancillaries

Photoresists are light-sensitive materials that undergo changes in their physical form when subjected to radiation. Photoresist ancillaries are associated materials that are used during lithography. The photoresist grades considered in the report are ArF immersion, g- and i-line, ArF dry, and KrF. The photoresist ancillaries considered in the report include anti-reflective coatings, photoresist strippers, developers, and edge bead removers.

Technavio's analysts forecast the global photoresist and photoresist ancillaries market to grow at a CAGR of 5.98% during the period 2017-2021.

Covered in this report

The report covers the present scenario and the growth prospects of the global photoresist and photoresist ancillaries market for 2017-2021. To calculate the market size, the report considers the sales of ArF immersion, ArF dry, KrF and g- and i-line. Photoresist ancillaries include the sales of anti-reflective coatings, developers, edge bead removers, and photoresist strippers.

The market is divided into the following segments based on geography:

- Americas
- APAC
- EMEA

Technavio's report, Global Photoresist and Photoresist Ancillaries Market 2017-2021, has been prepared based on an in-depth market analysis with inputs from industry experts. The report covers the market landscape and its growth prospects over the coming years. The report also includes a discussion of the key vendors operating in this market.

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Key vendors

- JSR,
- TOKYO OHKA KOGYA,
- Merck
- The Dow Chemical Company.

Other prominent vendors

- Avantor Performance Materials
- E. I. du Pont de Nemours and Company
- Fujifilm Electronic Materials
- KemLab
- LG Chem
- Microchemicals
- Shin-Etsu Chemical

Market driver

- Microfabrication requirements
- For a full, detailed list, view our report

Market challenge

- Regulatory challenges
- For a full, detailed list, view our report

Market trend

- Increasing use of NEMS technology
- For a full, detailed list, view our report

Key questions answered in this report

- What will the market size be in 2021 and what will the growth rate be?
- What are the key market trends?
- What is driving this market?
- What are the challenges to market growth?
- Who are the key vendors in this market space?
- What are the market opportunities and threats faced by the key vendors?
- What are the strengths and weaknesses of the key vendors?

You can request one free hour of our analyst's time when you purchase this market report. Details are provided within the report.

Complete Report Details @ <https://www.wiseguyreports.com/reports/1751452-global->

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- Merck
- TOKYO OHKA KOGYO
- The Dow Chemical Company
- Other prominent vendors

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CONTACT US:

NORAH TRENT

Partner Relations & Marketing Manager

sales@wiseguyreports.com

www.wiseguyreports.com

Ph: +1-646-845-9349 (US)

Ph: +44 208 133 9349 (UK)

Norah Trent

WiseGuy Research Consultants Pvt. Ltd.

+1 646 845 9349 / +44 208 133 9349

[email us here](#)

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